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# REQUEST FOR ACCESS OF ABANDONED APPLICATION UNDER 37 CFR 1.14(a)

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In re Application of

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09/061318

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I hereby request access under 37 CFR 1.14(a)(3)(iv) to the application file record of the above-identified ABANDONED application, which is: (CHECK ONE)

☒ (A) referred to in United States Patent Number 6267125 column \_\_\_\_\_

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US006267125B1

(12) **United States Patent**  
**Bergman et al.**

(10) **Patent No.:** **US 6,267,125 B1**  
 (45) **Date of Patent:** **Jul. 31, 2001**

(54) **APPARATUS AND METHOD FOR  
 PROCESSING THE SURFACE OF A  
 WORKPIECE WITH OZONE**

0 548 596 A2 6/1993 (EP) .  
 0 702 399 3/1996 (EP) .  
 2 287 827 9/1995 (GB) .  
 52-12063 4/1977 (JP) .

(75) Inventors: **Eric J. Bergman; Mignon P. Hess,**  
 both of Kalispell, MT (US)

(73) Assignee: **Semitool, Inc.,** Kalispell, MT (US)

(\*) Notice: Subject to any disclaimer, the term of this  
 patent is extended or adjusted under 35  
 U.S.C. 154(b) by 0 days.

(21) Appl. No.: **09/677,934**

(22) Filed: **Oct. 3, 2000**

**Related U.S. Application Data**

(60) Division of application No. 09/061,318, filed on Apr. 16,  
 1998, which is a continuation-in-part of application No.  
 08/853,649, filed on May 9, 1997.

(51) **Int. Cl.**<sup>7</sup> ..... **B08B 3/02**

(52) **U.S. Cl.** ..... **134/102.1; 134/102.3;**  
**134/148; 134/153; 134/902**

(58) **Field of Search** ..... **134/102.1, 102.3,**  
**134/102.2, 902, 186, 148, 153**

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*Primary Examiner*—Frankie L. Stinson

(74) *Attorney, Agent, or Firm*—Lyon & Lyon LLP

(57) **ABSTRACT**

An apparatus for supplying a mixture of a treatment liquid  
 and ozone for treatment of a surface of a workpiece, and a  
 corresponding method are set forth. The preferred embod-  
 iment of the apparatus comprises a liquid supply line that is  
 used to provide fluid communication between a reservoir  
 containing the treatment liquid and a treatment chamber  
 housing the workpiece. A heater is disposed to heat the  
 workpiece, either directly or indirectly. Preferably, the work-  
 piece is heated by heating the treatment liquid that is  
 supplied to the workpiece. One or more nozzles accept the  
 treatment liquid from the liquid supply line and spray it onto  
 the surface of the workpiece while an ozone generator  
 provides ozone into an environment containing the work-  
 piece.

**25 Claims, 6 Drawing Sheets**

